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APPLICATION NO.	FILING DATE	FIRST NAMED INVENTOR	ATTORNEY DOCKET NO.	CONFIRMATION NO.	
09/493,942	01/28/2000	James Y.C. Chang	36491/LTR/B600	2849	
26111 75	590 03/18/2003				
	SSLER, GOLDSTEI	EXAMINER			
	ORK AVENUE, N.W., S N, DC 20005-3934	SUITE 600	DONOVAN, LINCOLN D		
			ART UNIT	PAPER NUMBER	
			2832	nG	
· ,			DATE MAILED: 03/18/2003	27	

Please find below and/or attached an Office communication concerning this application or proceeding.

Office Action Summary

Application No. 09/493,942

Applicant(s)

Chang

Examiner

Lincoln Donovan

Art Unit 2832



	The MAILING DATE of this communication appears	on the	e co	ver sh	eet with	the correspondence address	
	for Reply						
	ORTENED STATUTORY PERIOD FOR REPLY IS SET MAILING DATE OF THIS COMMUNICATION.	то е	XPI	RE	3	MONTH(S) FROM	
- Extens	ions of time may be available under the provisions of 37 CFR 1.136 (a). In a date of this communication.	no even	it, ho	wever, m	nay a reply	be timely filed after SIX (6) MONTHS from the	
- If NO p - Failure - Any re	period for reply specified above is less than thirty (30) days, a reply within the period for reply is specified above, the maximum statutory period will apply a to reply within the set or extended period for reply will, by statute, cause the ply received by the Office later than three months after the mailing date of the patent term adjustment. See 37 CFR 1.704(b).	nd will e applic	expire ation	SIX (6) to beco	MONTHS 1 me ABAND	from the mailing date of this communication. ONED (35 U.S.C. § 133).	
Status							
1) 💢	Responsive to communication(s) filed on <u>Dec 11, 2</u>	002				·	
2a) 🗌	This action is FINAL . 2b) 🗓 This act	ion is	no	n-final			
3) 🗆	Since this application is in condition for allowance except for formal matters, prosecution as to the merits is closed in accordance with the practice under <i>Ex parte Quayle</i> , 1935 C.D. 11; 453 O.G. 213.						
Disposi	tion of Claims						
4) 💢	Claim(s) 1-7, 10-12, 14, 15, and 17-28					is/are pending in the application.	
4	a) Of the above, claim(s) 17-23					is/are withdrawn from consideration.	
5) 🗌	Claim(s)					is/are allowed.	
6) 💢	Claim(s) 1-7, 10-12, 14, 15, and 24-28					is/are rejected.	
7) 🗆	Claim(s)					is/are objected to.	
8) 🗆	Claims						
Applica	ition Papers						
9) 🗆	The specification is objected to by the Examiner.						
10)	The drawing(s) filed on is/are	a) 🗆	ac	cepte	d or b)	\square objected to by the Examiner.	
	Applicant may not request that any objection to the d	rawin	g(s)	be he	ld in abe	eyance. See 37 CFR 1.85(a).	
11)	The proposed drawing correction filed on			is:	: a)□ :	approved b) \square disapproved by the Examiner.	
	If approved, corrected drawings are required in reply t	to this	of	fice ac	tion.		
12)	The oath or declaration is objected to by the Exami	ner.					
Priority	under 35 U.S.C. §§ 119 and 120						
13)	Acknowledgement is made of a claim for foreign pr	riority	un	der 35	U.S.C.	. § 119(a)-(d) or (f).	
a) [☐ All b) ☐ Some* c) ☐ None of:						
	1. \square Certified copies of the priority documents hav	e bee	en re	eceive	d.		
	2. \square Certified copies of the priority documents hav	e bee	en re	eceive	d in Apı	plication No	
	3. Copies of the certified copies of the priority de application from the International Bure	au (P	CT	Rule 1	7.2(a)).		
	ee the attached detailed Office action for a list of the						
	Acknowledgement is made of a claim for domestic						
a) L							
15) ∟	Acknowledgement is made of a claim for domestic	prior	ity (maer	35 U.S.	.C. 99 120 and/or 121.	
Attachm	ent(s) ptice of References Cited (PTO-892)	4)	Inte	view Su	mmarv (PT	O-413) Paper No(s)	
	otice of Draftsperson's Patent Drawing Review (PTO-948)	_				nt Application (PTO-152)	
_	formation Disclosure Statement(s) (PTO-1449) Paper No(s).	6)					

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DETAILED ACTION

Claim Rejections - 35 USC § 103

- 1. The following is a quotation of 35 U.S.C. 103(a) which forms the basis for all obviousness rejections set forth in this Office action:
 - (a) A patent may not be obtained though the invention is not identically disclosed or described as set forth in section 102 of this title, if the differences between the subject matter sought to be patented and the prior art are such that the subject matter as a whole would have been obvious at the time the invention was made to a person having ordinary skill in the art to which said subject matter pertains. Patentability shall not be negatived by the manner in which the invention was made.
- 2. Claims 1-3, 5-7, 10-12, 14 and 24-28 are rejected under 35 U.S.C. 103(a) as being unpatentable over Kuettner et al. [US 5,852,866] in view of Ikeda et al. [US 5,492,856] and Folker et al. [US 5,777,539].

Kuettner et al. disclose an integrated inductor comprising:

- a spiral inductor metalization pattern [figure 3] including a plurality of parallel tracks [21] in a spiral pattern having a square configuration on a common layer, each track having first and second ends.

Kuettner et al. discloses the instant claimed invention except for: the metalization pattern being formed on a substrate and the first and second ends being connected together.

Ikeda et al. disclose a monolithic inductor being formed on a substrate.

It would have been obvious to one having ordinary skill in the art at the time the invention was made to form the metalization patterns of Kuettner et al. on a substrate, as suggested by Ikeda et al., for the purpose of easily integrating the inductor.

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Folker et al. disclose a spiral inductor metalization pattern [figure 2] having a plurality of conductor lines coupled together at their starting and end points.

It would have been obvious to one having ordinary skill in the art at the time the invention was made to couple the end points of the conductors of Kuettner et al., as modified, as suggested by Folker et al., for the purpose of reducing the resistance of the winding.

Regarding claim 2, official notice is taken that a CMOS process is a well known method of producing an integrated inductor.

Regarding claim 6, Kuettner et al. and Folker et al. disclose multiple layers interconnected with vias [25].

Regarding claims 10-12, Ikeda et al. discloses the use of N+ diffusion layer directly beneath the metal layer [figure 2].

It would have been obvious to one having ordinary skill in the art at the time the invention was made to use the n+ diffusion layer for the purpose of generating a desired reverse bias and increasing the Q factor. The specific arrangement of the layer would have been an obvious design consideration based on the specific application and operating environment of the inductor.

3. Claims 4 and 15 are rejected under 35 U.S.C. 103(a) as being unpatentable over Kuettner et al., as modified, as applied to claim 1 above, and further in view of Fawal et al. [US 6,049,258].

Kuettner et al., as modified, discloses the instant claimed invention except for the specific shape of the inductor metalization layers and the use of the inductor in transmission lines.

Regarding claim 4, Fawal et al. discloses the use of orthogonal shaped metalization layers.

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It would have been obvious to one having ordinary skill in the art at the time the invention was made to use the orthogonal shape of Fawal et al. in Kuettner et al., as modified, for the purpose of optimizing the sizing of the inductor.

Fawal et al. discloses the inductor being used for transmission lines.

It would have been obvious to one having ordinary skill in the art at the time the invention was made to use the transmission design of Fawal et al. with the inductor design of Kuettner et al., as modified, for the purpose of optimizing the transmission network.

Response to Arguments

4. Applicant's arguments with respect to claims 1-12, 14-15 and 24-28 have been considered but are moot in view of the new ground(s) of rejection.

Conclusion

5. Any inquiry concerning this communication or earlier communications from the examiner should be directed to Examiner Lincoln Donovan whose telephone number is (703) 308-3111.

The fax number for this Group is (703)308-7724.

Any inquiry of a general nature or relating to the status of this application or proceeding should be directed to the Group receptionist whose telephone number is (703)308-0956.

LDD

March 4, 2003